ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

Method for forming silicon dioxide film using siloxane

Application Number: 10/782094

Confirmation Number: 4756

First Named Applicant: Jae-eun Park
Attorney Docket Number: SAM-0483

Art Unit: Examiner:

Search string: (3313792).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	3313792	1967-04-11	Duck, et al.			

Remarks

Note: Remarks are not for responding to an office action.

Part 1 of 1.

Signature

Examiner Name	Date